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Co-Packaged Optical-IO The Promise and the Challenges

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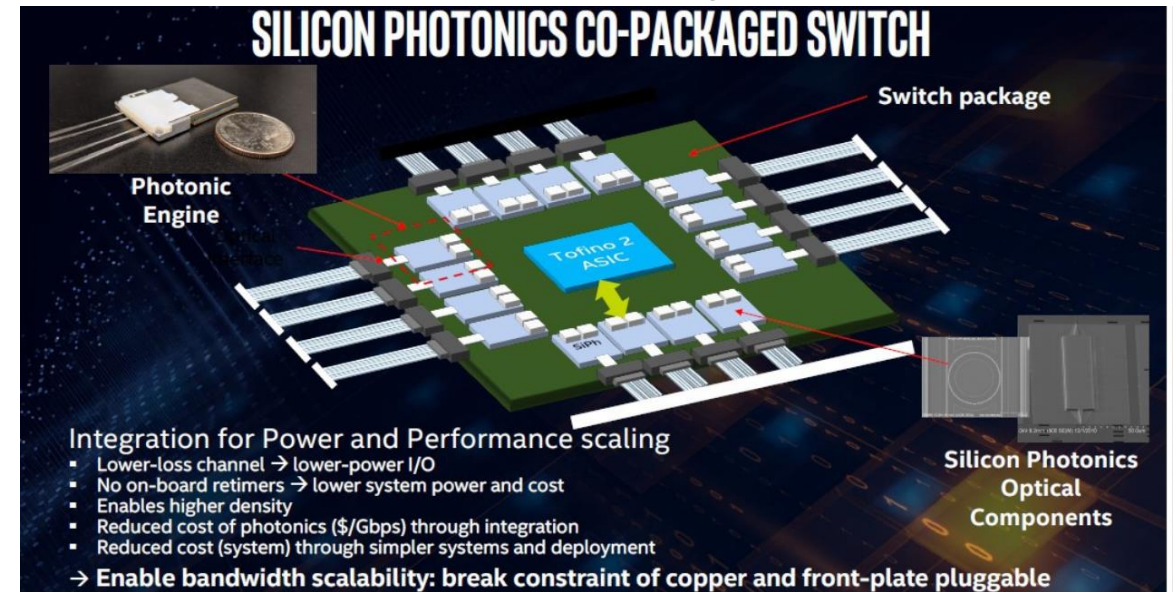
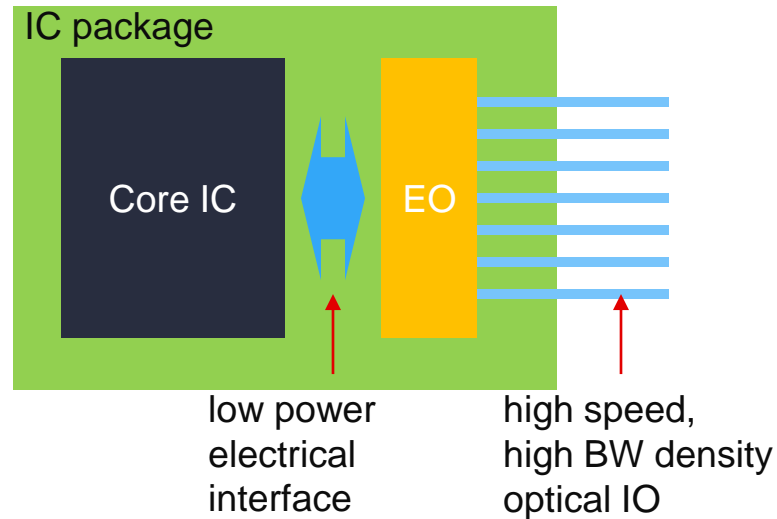


Outline

- ▶ What is co-packaged optical – IO?
- ▶ Why co-packaged optical – IO?
- ▶ Where are we now?
- ▶ Challenges to commercialization

What is Co-packaged Optical – IO?

All the cartoons of an IC with co-packaged optics look like this



- ▶ Optical transceiver (aka “EO converter” or “optical engine”) inside IC package
- ▶ Not monolithically integrated on IC die
 - Internal interface to IC: low power, highly parallel, lower data rate, electrical
 - External interface: high speed, high bandwidth density optical, directly coupled to fiber

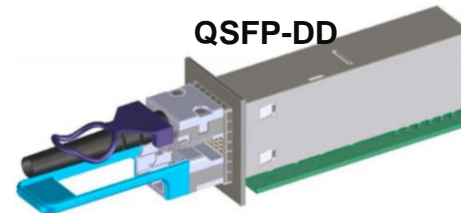
Why Co-packaged Optical – IO?

- ▶ Moving data between IC and optical TRx across line-card harder at higher data rate
 - Equalization: high power consumption
 - FEC: BW overhead, power consumption, latency
- ▶ Aggregated bandwidth
 - Optics on faceplate cannot support switch BW
- ▶ Fully packed faceplate impedes airflow
- ▶ Moving optics inside package
 - Improve **energy efficiency** (less equalization)
 - Increase **bandwidth density** (with **WDM**)
 - Reduce **latency** (no FEC)

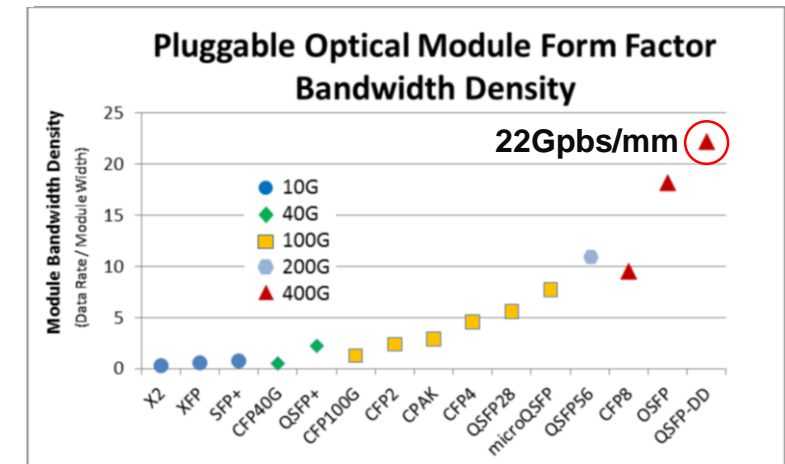
400G QSFP-DD power consumption 12W
 Energy efficiency: **30pJ/bit**

DARPA TA1: Photonically Enabled MCMs

	Phase 1	Phase 2	Phase 3
Key outcomes	10T technology demonstration*	Enhanced 10T demo* AND Packaged MCM demo	100T technology demo* AND Differentiating Access
Aggregate bandwidth	10 Tbps	10T demo: 10 Tbps MCM: proposer defined	100 Tbps
Energy per bit	2.5 pJ/bit	1 pJ/bit	1 pJ/bit
Edge bandwidth density	1 Tbps/mm	2 Tbps/mm	2 Tbps/mm



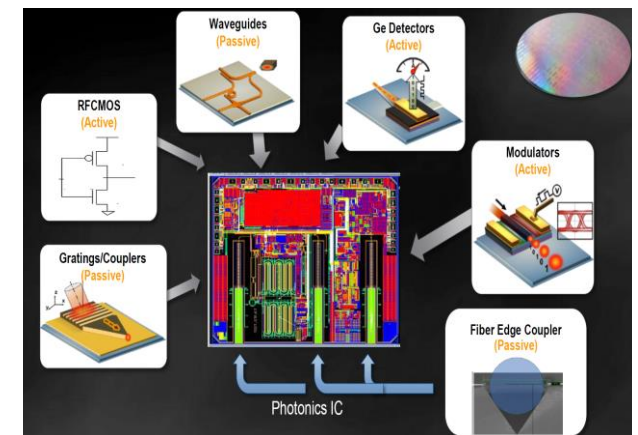
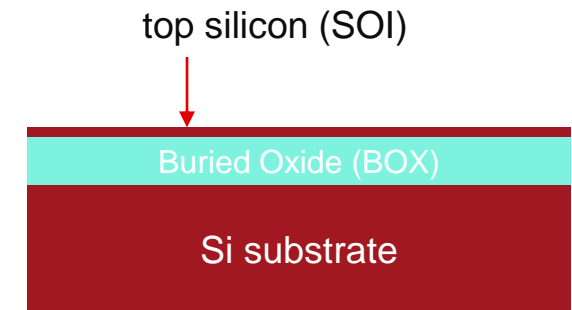
36 ports in 1RU, supporting 14.4Tbps



How data move from IC to optical transceivers today

Silicon Photonics for Integrated Optics (datacom)

- ▶ Silicon photonics: photonics components and circuits built on silicon wafers using CMOS compatible processes
 - High volume production in CMOS fabs with advanced tools and processes
 - Built on SOI wafers – buried oxide (BOX) necessary as bottom cladding of Si waveguide
 - Si makes excellent waveguides and supports integration photonics circuits
 - Transparent to light with wavelength $>1.1\mu\text{m}$
 - Strong guiding allows small waveguides ($<0.5\mu\text{m}$ wide) and tight bends ($r=5\mu\text{m}$)
 - Assortment of high-quality passive components available, but WDM components remains a challenge (more later)
 - High speed modulation based on plasma dispersion effect
 - Epitaxial growth of germanium on silicon – well developed process
 - High speed detectors (O-band to C-band)
 - Electro-absorption modulator (Franz-Keldysh effect)

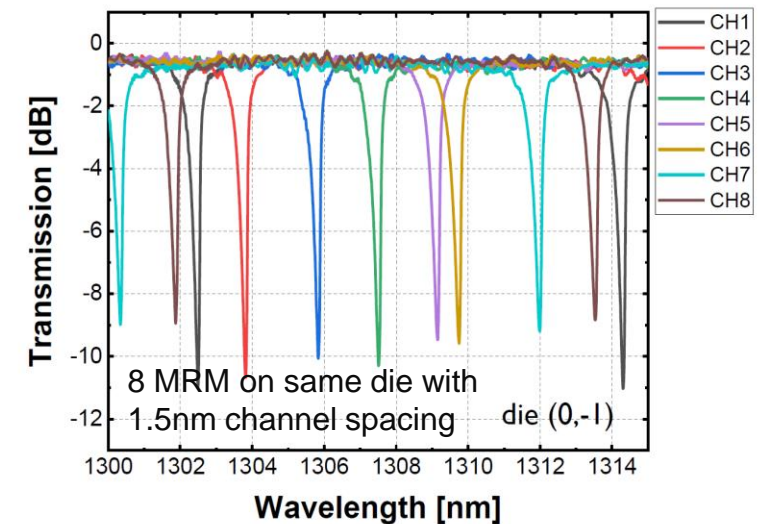
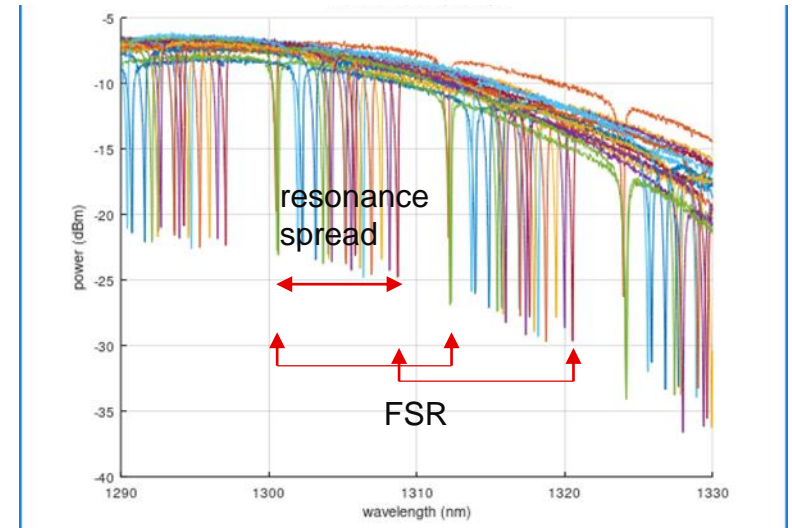


GlobalFoundries Si Photonics Platform

Fundamental challenges & their mitigations

- ▶ Si does not produce light with electrical pumping
 - Die bonding of III-V gain medium for on wafer laser
 - Efforts in native light source not yet practical
 - Off-wafer (external) light source
- ▶ Phase error in Si waveguide
 - Caused by small variation in WG width or thickness
 - Many effective WDM devices (e.g. AWG and Echelle grating) built on other platforms are not manufacturable in Si
 - Phase tuning – effective partial solution
 - Thermal tuning (local heaters)
 - Tuning with carrier injection (section of forward biased PIN)
- ▶ Temperature sensitivity (index change with temp)
 - Temperature insensitive design
 - Thermal tuning

Transmission spectra of same ring resonator on 20 different reticle sites of same wafer



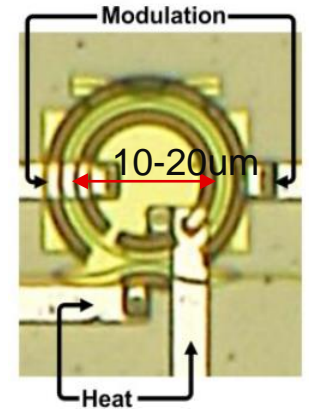
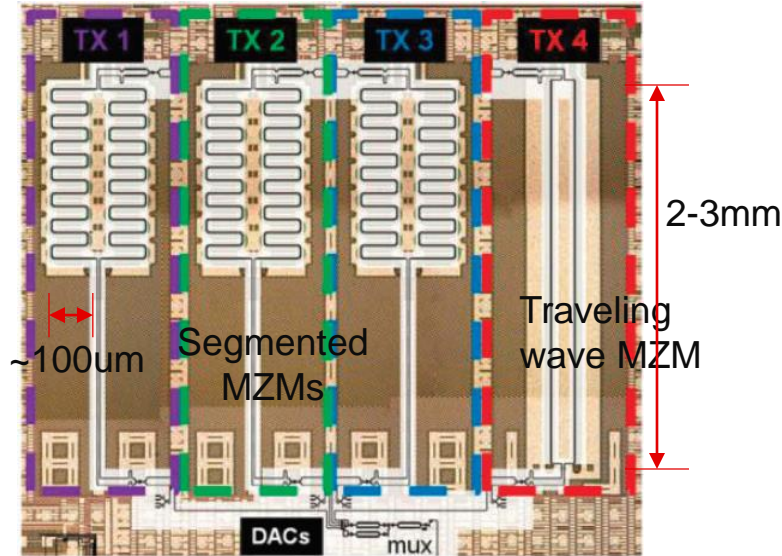
Technology Choices for Co-packaged Optical – IO

▶ Active components for Si TRx

- Modulator choices for Tx
 - MZM, **MRM**, and EAM
- Photodetector choices for Rx
 - **Ge PIN** or APD

▶ Best choice for co-packaging

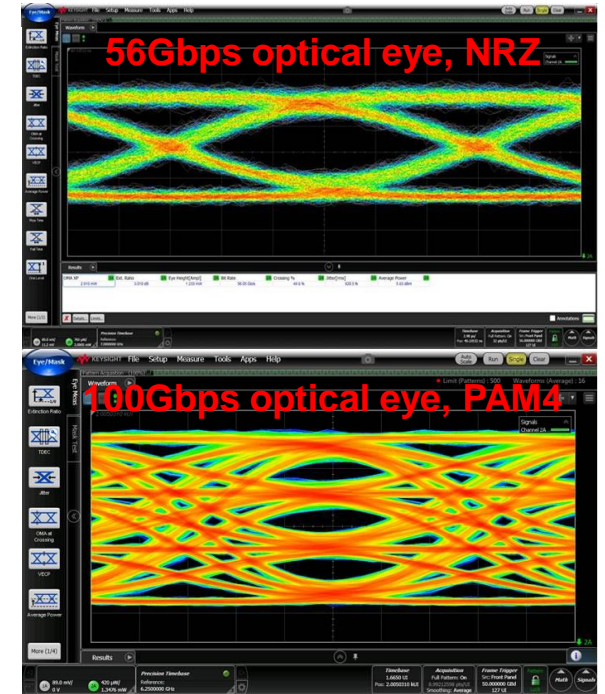
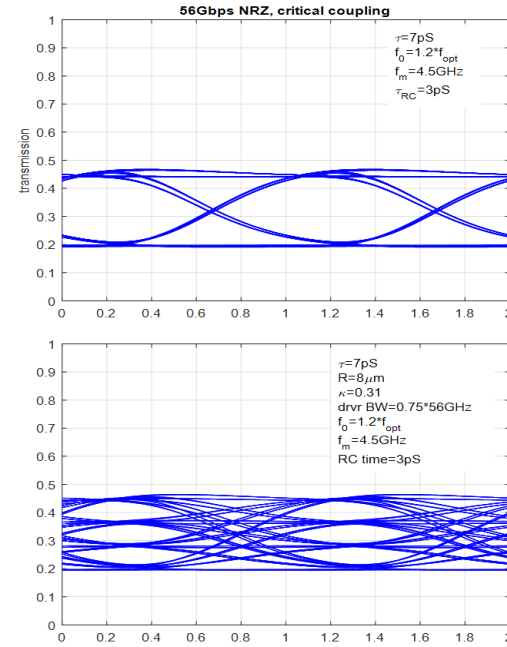
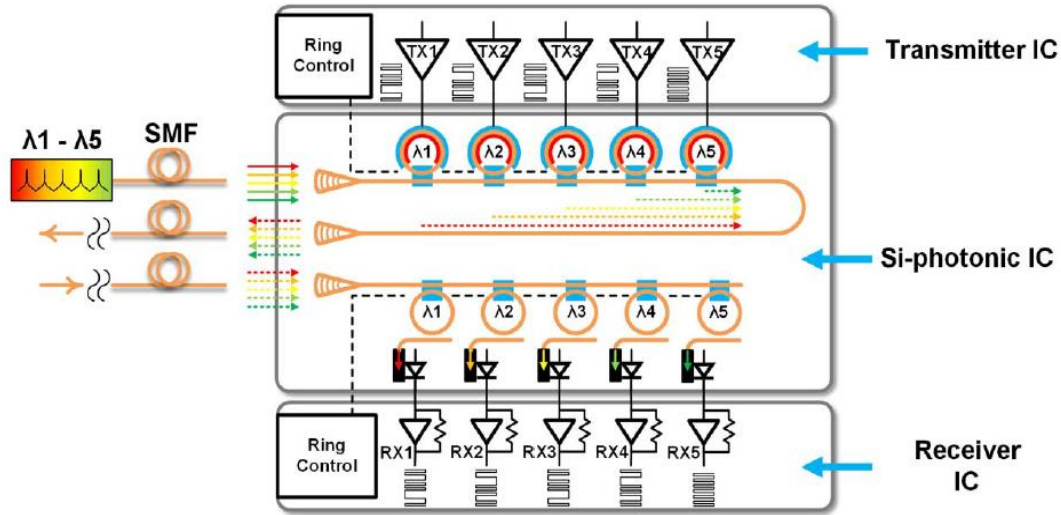
- Small size, low power, supporting WDM
- Modulator choice: MRM
- Detector choice: Ge PIN



modulator type	size	driving power	speed	temperature sensitivity	wavelength selectivity	operating wavelength	WDM
MZM (balanced)	large (L~2mm)	high	very good (segmented)	low	not selective	O and C band	CWDM & DWDM need MUX/deMUX
MRM	small (R<10um)	low	good	high*	very selective*	O and C band	DWDM with external source
EAM (FK)	small (L<100um)	low	good	medium	selective	C band	does not work well with WDM

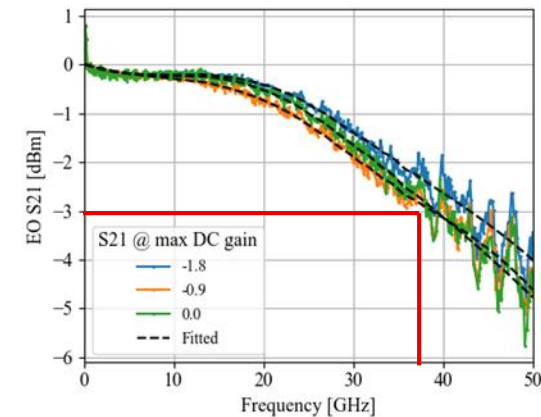
* mitigated with thermal tuner

More on Si micro-ring modulators (MRM)



MRM optical eye diagrams, Xilinx/IMEC

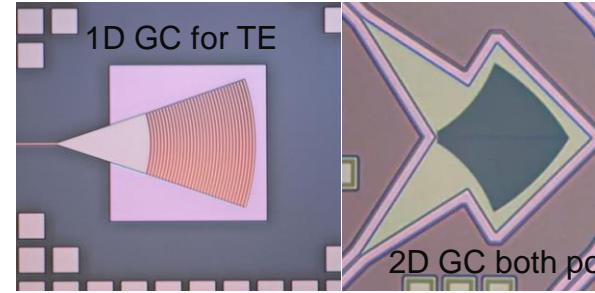
- ▶ Works well with a DWDM light source
- ▶ High speed to support >50GB symbol rate
 - BW > 35GHz



Architectural Options

▶ Monolithic vs. heterogeneous

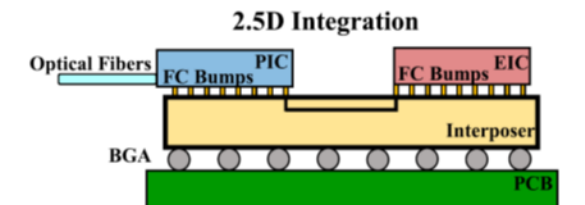
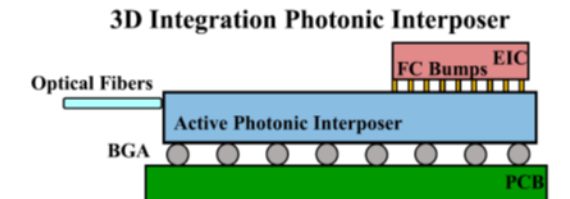
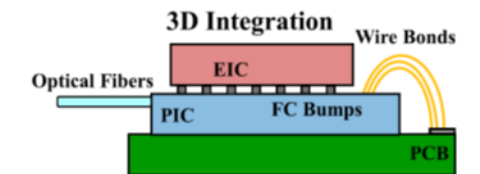
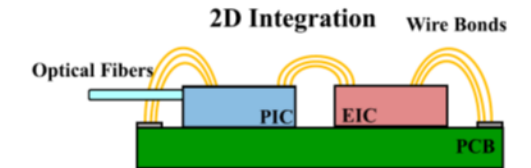
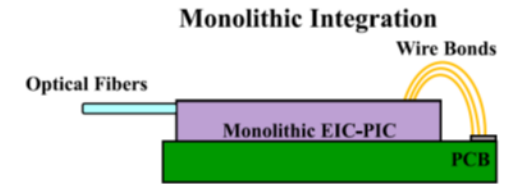
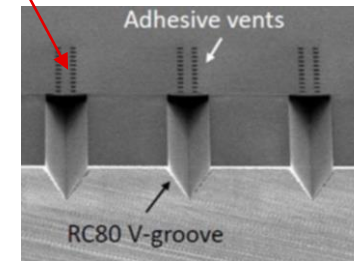
- Early efforts all on monolithic
- Heterogeneous offers more flexibility
 - Choice of base wafer. Photonics and electronics favor different SOI
 - Separate process node for electronics and photonics
- Monolithic still alive (GF 9WG & 45SPCLO)
 - Cost and convenience



▶ Coupling options

- Surface coupling – grating couplers
 - Wavelength and polarization dependency. Passive alignment possible
 - On wafer testing
 - With beam expanding μ -lens -> connector with relaxed alignment tolerance
- Edge coupling
 - With V-grooves – butt couple to fiber, passive alignment. Incompatible with TSV
 - Free-space coupling w/o V-grooves. Active alignment. Free space coupling optics

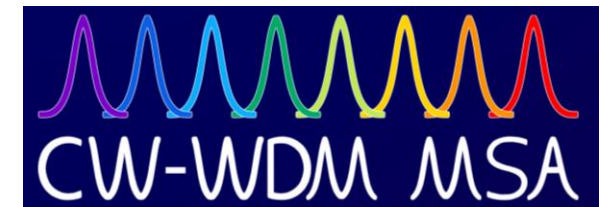
suspended SSC



J. Lightwave Tech., V 38, No. 13, July 1, 2020

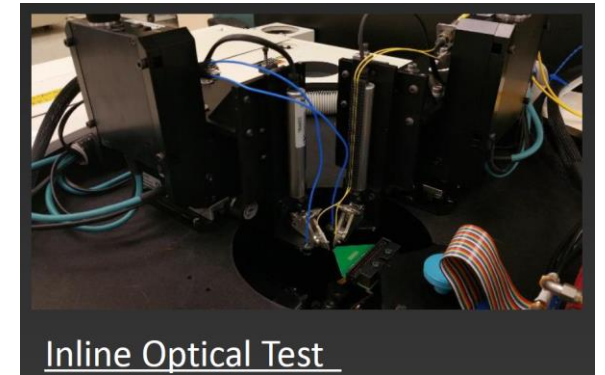
Ecosystem buildup

- ▶ Co-package optical – IO technology driving force
 - Data center and HPC customers want it
 - Microsoft & Facebook form “Co-packaged Optics Collaboration” (<http://copackagedoptics.com/>)
 - IC companies are evaluating feasibility
 - Startups and established photonics companies building optical engines for CPO
 - CW-WDM MSA recently formed to define WDM channel plan for CPO (<https://cw-wdm.org/>)
- ▶ EDA tool vendors adding photonics capabilities
 - Curvilinear layout
 - Device models, co-simulation support, photonics LVS
- ▶ Si Photonics foundries
 - R&D fabs and smaller commercial foundries have been providing MPW or dedicated wafer runs
 - GF advancing 45SPCLO (migrating from 9WG) – photonics and CMOS (monolithic) integration
 - Other major foundries testing the waters, seriously assessing business opportunity and potential
- ▶ Single mode fiber ribbons and multi-fiber connectors (MPO) gained traction in optical transceivers
 - More to be done to support co-packaged optics



Challenges for Co-packaged Optical – IO

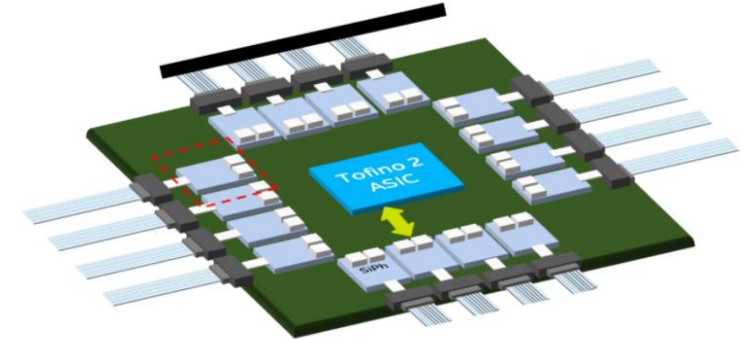
- ▶ Robust and efficient WDM light source
 - Can one of the comb laser schemes deliver the performance?
 - Conventional DFB array + MUX work as external source, but not an elegant solution
- ▶ Wafer level testing, KGD identification
 - How to perform wafer level testing when edge coupling is used?
 - Can PCM parts provide sufficient information?
- ▶ Optical assembly
 - Fiber coupling and alignment
 - Fiber assembly is a new process in IC packaging
 - Can optical sub-assemblies survive solder reflow?
 - Active alignment is challenging even in conventional optical transceiver manufacturing
 - High cost, low through put
 - Reducing coupling loss via both design and process improvement still critical
 - Lower loss = higher energy efficiency, higher link budget, and lower latency



Challenges for co-package optical – IO, cont'd

▶ Fiber management

- Hundreds of fibers per package
 - Fiber ribbons coming out from all 4 sides?
- Handing of fiber ribbons
- Need breakout to allow flexible connectivity
 - some fibers in a ribbon may need to connect to local light sources
 - not all fibers in a ribbon are connecting same two nodes
- What about fiber breakage?
 - Fiber receptacles preferred over pigtailed – externalize fiber breakage risk
 - Include redundancy in design?



Source: Intel.

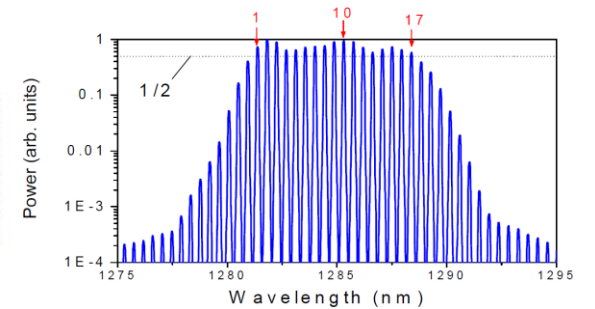
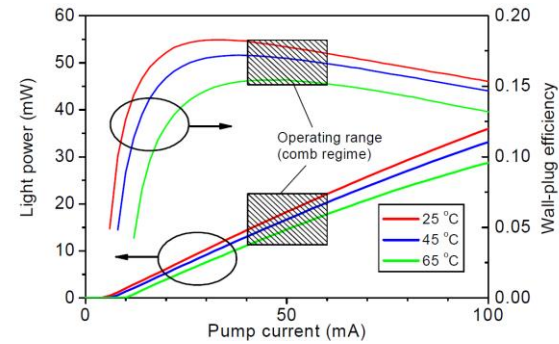
▶ New thermal management challenges

- A 100Tbps switch produces tremendous amount of heat
 - even with energy efficient optical – IO
- Would optical – IO hardware on the peripheral of package interfere with heat removal?

Promising comb laser source for WDM

► Comb laser source

- No wavelength multiplexing needed
- Uniform line spacing
- Mode – locked QD comb
 - Elegant single chip solution with high WPE
 - Performance concerns
 - RIN (noise) of individual laser lines
 - Wavelength range
- Non-linear Kerr comb
 - Wide spectrum with flexible spacing
 - Draw backs
 - Channel power uniformity
 - Conversion efficiency (simulation > 60%. Reported ~40%)



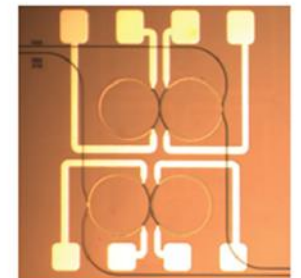
A QD comb laser with 17 lines whose power is within 3dB of each other



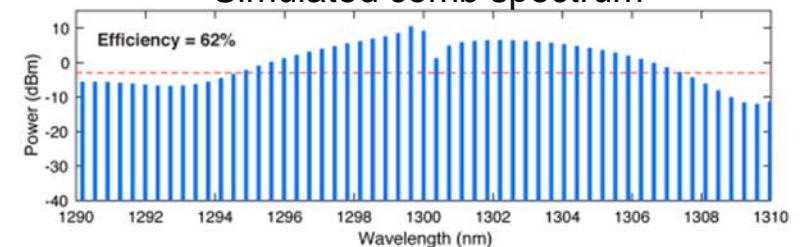
Normal GVD Comb Source at 1300 nm



- Mode-interaction using coupled silicon Nitride microring resonators
- 640 × 2200 nm cross section, 65 GHz FSR
- 200 mW pump power in bus waveguide



Simulated comb spectrum



Kerr comb

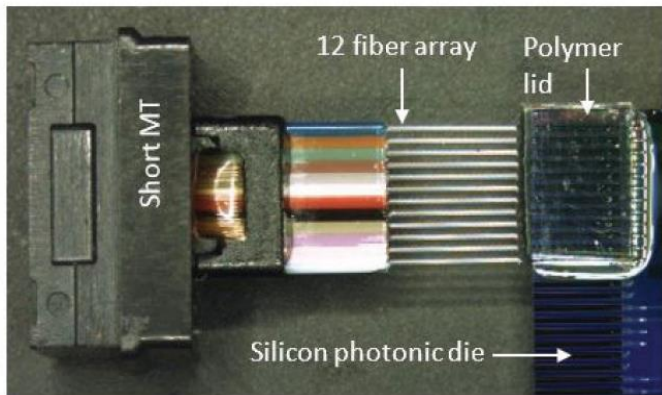
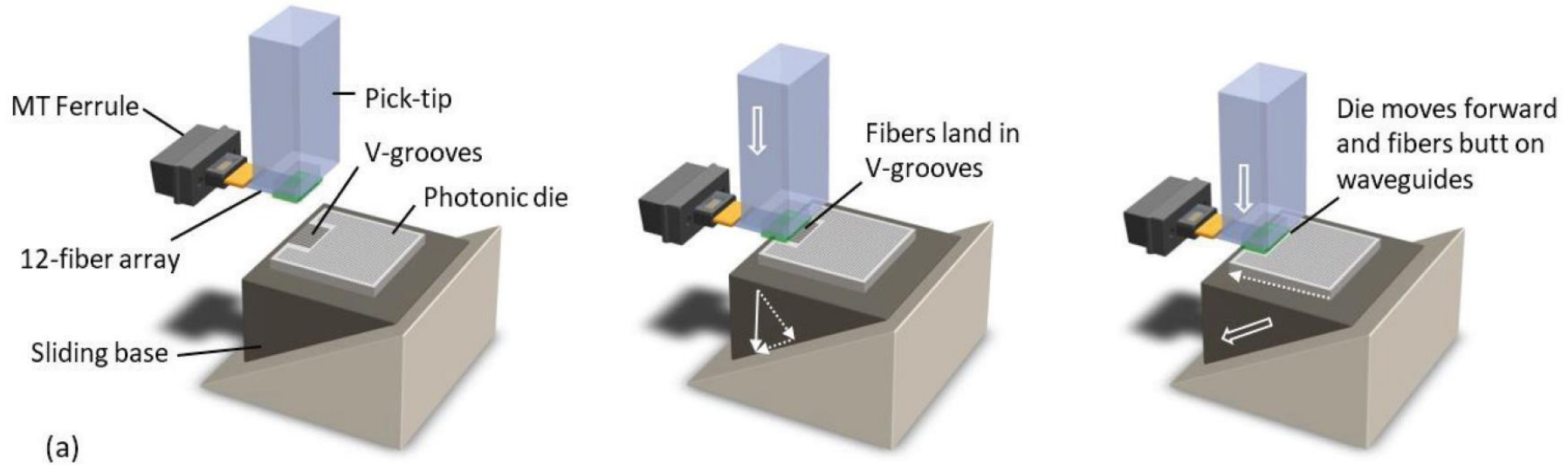
To summarize

- ▶ Co-packaged optical – IO promises
 - Significant improvement in energy efficiency
 - Significant increase in bandwidth density
 - Potential reduction in latency
- ▶ Basic silicon photonics-based CPO technology in place
- ▶ Ecosystem is building up
- ▶ Many challenges still being addressed
 - Robust WDM and efficient light source
 - Wafer level testing for KGD
 - Fiber attachment, optical alignment process development
 - Fiber management

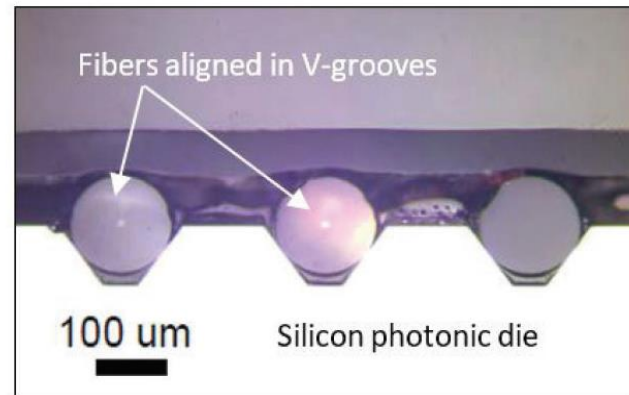
Backup



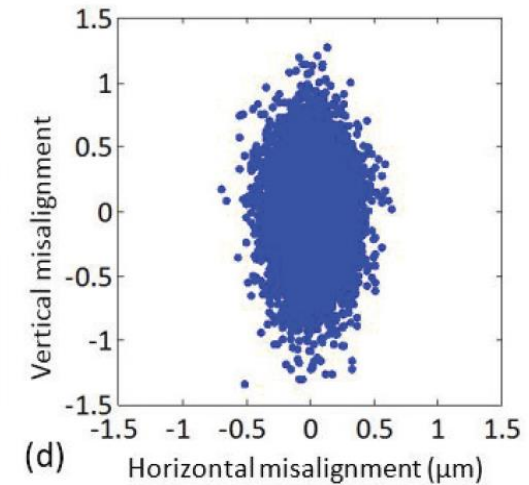
Fiber ribbon assembly into V-grooves by IBM



(b)



(c)



(d)



Thank You

